

(130) A New Silicon Sensor for Hot Metal Measurements

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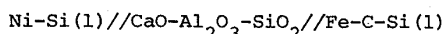
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I. INTRODUCTION

An electrochemical sensor has been designed for the direct measurement of silicon content in hot metal. A reproducible EMF vs wt.%[Si] relationship was obtained for measurements in carbon-saturated Fe-C-Si melts at 1,400°C and Si contents from 0.05 to 1.80 wt.%. (1)

II. EXPERIMENTAL

The sensor investigated is based on the cell



where the molten Ni-Si alloy represents the silicon reference and the molten Fe-C-Si alloy the hot metal of variable Si content, respectively.

The design of the sensor is schematically shown in Figure 1. All measurements were carried out at 1,400°C in a Tammann furnace using carbon crucibles.

III. RESULTS AND DISCUSSION

MEASURED EMF DATA : Stable EMF readings were obtained after 30 to 60 seconds as shown in Figure 2. Photo 1 shows a longitudinal section of a used sensor. Since the thermoelectric voltage, E_{th} , between nickel and graphite is involved in the measured EMF, a correlation had to be made according to

$$E(\text{galvanic}) = E(\text{measured}) - E_{th} \quad [\text{volt}]$$

From the measurements,

$$E_{th} = 0.03 \quad [\text{volt}]$$

is obtained at 1,400°C.

The experimental data of $E(\text{galvanic})$ vs $\log \text{wt.\%[Si]}$ are given in Figure 3 and may be expressed as

$$E(\text{galvanic}) = -0.096 \cdot \log \text{wt.\%[Si]} - 0.123 \quad [\text{volt}]$$

The pre-logarithmic factor 0.096 is equivalent to a charge transfer number of $n=3.5$.

CALCULATED EMF DATA : Assuming $n=4.0$ and $t_{ion}=1$, the EMF of the silicon concentration cell should follow the relationship

$$E = -\frac{RT}{4F} \ln \frac{a_{Si}(\text{Fe})}{a_{Si}(\text{Ni})}$$

$a_{Si}(\text{Fe})$ and $a_{Si}(\text{Ni})$ are calculated from the existing thermodynamic data (2)-(5). There is only a small deviation of the experimental data from the calculated line represented by a slightly different slope which results in an equivalent charge transfer number of $n=3.5$ instead of $n=4.0$.

REFERENCE :

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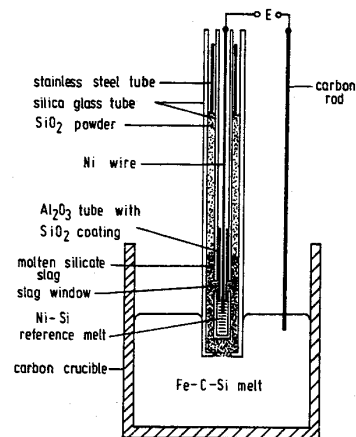


Fig. 1. Schematic sketch of the silicon sensor

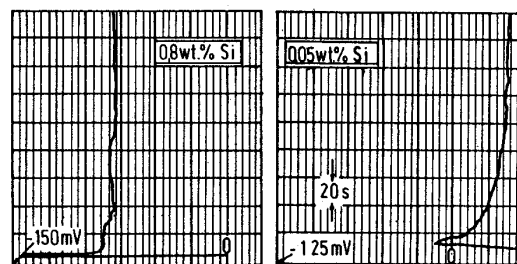


Fig. 2. EMF readings from sensors at various Si contents



Photo 1. Longitudinal section of a used Si sensor

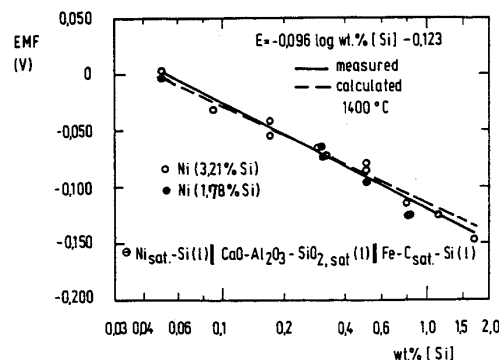


Fig. 3. Corrected EMF vs wt.%[Si] in carbon-saturated Fe-C-Si melts at 1,400°C